



Docket 68529/A/JLT

FEB 6

In the United States Patent and Trademark Office

In re Application of:

Neil F. Haley, et al

RADIATION-SENSITIVE COMPOSITION CONTAINING A RESOLE RESIN, A NOVOLAC RESIN, AN INFRARED ABSORB-ER AND A TRIAZINE AND USE THEREOF IN LITHOGRAPHIC PRINTING PLATES

Serial No. 08/534,135

Filed September 26, 1995

Honorable Assistant Commissioner For Patents Washington, D.C. 20231

Sir:

Group Art Unit: 1113

Examiner: to be assigned

I hereby certify that this correspondence is being deposited TODAY with the United States Postal Service as first class mail in an envelope addressed to Assistant Commissioner For Patents,

LETTER OF INQUIRY

This application was mailed September 26, The filing receipt was received at our office November 7, 1995. We have yet to receive the first Office Action. Please advise us regarding the status of this application. Thank you.

Respectfully submitted,

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